

Paul M. Rivard discusses David J. Kappos' legacy in Chemical & Engineering News

November 29, 2012

Mr. Rivard discusses David J. Kappos' role at the U.S. Patent and Trademark Office in a *Chemical & Engineering News* article titled, "David J. Kappos to Step Down from Agency in January." Please click here to read the article.

Posted: November 29, 2012